Allo C-276 (UNS N10276) i.—an a __eni ic nickel-mol bden_m-chromi. m allo i h a _mall addi ion of __ng__en. I i.—one of he premier corro_ion re_i.—an ma erial.—a ailable for proce___ind__rie... Allo C-276 ha.—e cellen corro_ion re_i.—ance in bo h o idi ing and red_cing en ironmen ...

The combina ion of he high mol bden m and chromi m con en , along i h he addi ion of ng en, make Allo C-276 highl reil an o chloride rerection cracking, pi ing, cre ice corrolion and general corrolion.

Allo C-276 can opera e in o idi ing a mo phere. n o 1900 F (1038 C), ho e er, he allo lack-fzcien chromi m con en o opera e ce fill in he morrongl o idi ing en ironmen like ho, concen ra ed ni ric acid.

The lo carbon con en of Allo C-276 enable. he allo o be iii ed in he a. elded condi ion. I canno be hardened b hea rea men, b. can be hardened b cold orking. The allo ha. a higher

Allo C-276 i. one of he premier corrolion relican ma erial. ha performe cep ionall ell in bo ho idi ing and redicing en ironmental relication. I relication cracking, pi ing, cre ice and general corrolion. The allo i. also relican o carbide precipi a ion during elding enabling i o be litied in he also elded condi ion.

In chemical processing applications, he allo have ceptional resistance of the first, he drochloric, formic, ace ic and phosphoric acides Allo C-276 performs ell in en ironmen such acide chlorides, soll en suand ace ic anh dride, The allo is one of he fe grades ha i hounds e chlorine gas, he pochlori e and chlorine dio ide sols ions.

Allo C-276 i_highl re_i_an o concen ra ed_ol_ion_of o idi ing_al_incl_ding iron and copper chloride. I al_o perform_ ell in ea a er, e-peciall_nder cre ice condi ion_ here o her freq_en I ed allo ed allo ed allo eel, Allo 400 and Allo 625 fail.

The opera ing condi ion. of _e_ga._de__lf_ri_a ion ...em._offer a challenging en ironmen for corro.ion re.i._an ma erial.. Scr_bber liq_or._and ga._conden_a e_of en con ain chloride.. Allo C-276 ha._been_ho n o i h._and higher chloride le el_ han o her grade._before he on.e of locali ed corro.ion in he.e.__em..

Allo C-276 i. ed e en.i el in he reco er and proce. ing of .o. r. na_ral ga.- hich con ain. h drogen __lzde along i h carbon dio ide and chloride.. Carbon and allo __eel__canno i h._and hi__corro.i e en ironmen . The are __biec o fail_re b __lzde __re.__cracking or __re.__corro.ion cracking. The rich chemi_r of Allo C-276 make._i re.i._an o __o.ren ironmen __e en a high empera__re._in deep ell._

Allo C-276 can be ea.il and proce ed iii ing andard -hop fabrica ion prac ice--for a_eni ic _ainle.__eel_and nickel baled allo ...

H.F.m[∆]¹

The ho - orking empera_re range for Allo C-276 i-1600 2250 F (870 1230 C). The allo ho ld be a er quenched af er ho orking. Hea rea men irecommended af er ho orking o en__re ma im_m corro_ion re_i_ance.

F m.1 Allo C-276 hold be in he annealed condi ion for cold orking. The allo ha -a higher orkhardening ra e han he a eni ic ainle hich ho ld be aken in o con-idera ion. An in-proce---anneal ma be nece--ar i h a high degree of cold orking. If he allo __ndergoe__grea er han 15% deforma ion dering cold orking, a _ol__ion anneal ma be nece--ar.

Allo C-276 can be readil b mo---andard proce--e-incl_ding GTAW (TIG), PLASMA, GMAW (MIG/MAG) and SMAW (MMA). A po-- eld hear ea men i-no nece--ar . Br. hing i h a
--ainle----eel ire br. h af er elding ill remo e he hea in and prod_ce a __rface area ha doe._no req_ire addi ional pickling.

M = MMM

Allo C-276 hold preferabl be machined in he annealed condi ion. Since Allo C-276 i-prone o ork hardening, onl lo cing peedhold be ed and he cing ool hold be engaged a all ime. Adeq a e c dep h i nece ar o a re a oiding con ac i h he pre io ___ formed ork-hardened , one.

The informa ion and da a in hi_prod_c da a hee are acc_ra e o he be_ of o_r kno ledge and belief, b_ are in ended for informa ional p_roo_e_onl, and ma be re i.ed a an ime i ho_ no ice. Applica ion_ age_ed for he ma erial_are de_cribed onl o help reader_make heir o ne al_a_ion_and deci_ion_ and are nei her g_aran ee_nor o be con_r_ed a_e pre_or implied arran ie_of__iabili for he_e or o her applica ion_.